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 <https://doi.org/10.1075/cilt.319.002loc>

Pages ix–x of

Instrumental Studies in Arabic Phonetics

Edited by Zeki Majeed Hassan and Barry Heselwood

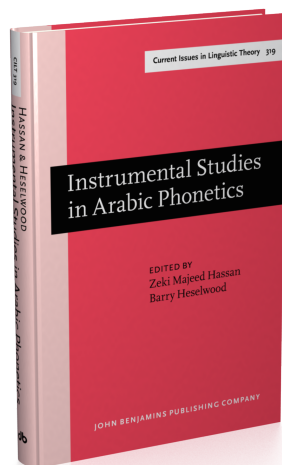
[*Current Issues in Linguistic Theory*, 319]

2011. xii, 365 pp.

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